

L Number	Hits	Search Text	DB	Time stamp
-	8011	"mass spectrometer"	USPAT	2003/03/26 11:29
-	2	"6420275"	USPAT	2003/03/26 13:46
-	26	("4104026" "4894529" "4920071" "4926021" "4990459" "5129991" "5151168" "5188723" "5232749" "5248614" "5259254" "5271798" "5315369" "5325730" "5364803" "5400665" "5441904" "5445994" "5501767" "5597444" "5633172" "5668394" "5691211" "5837598" "5851680" "5853492").PN.	USPAT	2003/03/26 11:41
-	1400	156/345.1 156/345.13 134/1.3 216/84	USPAT	2003/03/26 12:08
-	597	(nebuli\$3 aerosol mist\$3 vapor\$5) same sampl\$3 same (wafer semiconductor)	USPAT	2003/03/26 12:51
-	214935	422/\$ 222/\$ 250/288 600/\$	USPAT	2003/03/26 12:51
-	8041	(422/\$ 222/\$ 250/288 600/\$) and (wafer semiconductor)	USPAT	2003/03/26 12:51
-	3125	((nebuli\$3 aerosol mist\$3 vapor\$5) same sampl\$3)and (422/\$ 222/\$ 250/288 600/\$)	USPAT	2003/03/26 12:55
-	112	((nebuli\$3 aerosol mist\$3 vapor\$5) same sampl\$3)and (422/\$ 222/\$ 250/288 600/\$)) and peristaltic	USPAT	2003/03/26 12:56
-	448	((nebuli\$3 aerosol mist\$3 vapor\$5) same sampl\$3)and ((422/\$ 222/\$ 250/288 600/\$) and (wafer semiconductor))	USPAT	2003/03/26 12:55
-	27	((nebuli\$3 aerosol mist\$3 vapor\$5) same sampl\$3)and ((422/\$ 222/\$ 250/288 600/\$) and (wafer semiconductor))) and peristaltic	USPAT	2003/03/26 12:56
-	3792	356/316 356/36 250/288 356/237.2 356/237.3 356/237.4	USPAT	2003/03/26 13:48
-	951	(356/316 356/36 250/288 356/237.2 356/237.3 356/237.4) and (wafer semiconductor)	USPAT	2003/03/26 13:56
-	339	((356/316 356/36 250/288 356/237.2 356/237.3 356/237.4) and (wafer semiconductor)) and (liquid etchant)	USPAT	2003/03/26 13:57
-	6	((356/316 356/36 250/288 356/237.2 356/237.3 356/237.4) and (wafer semiconductor)) and (liquid etchant)) and (peristaltic)	USPAT	2003/03/26 13:57
-	26	((356/316 356/36 250/288 356/237.2 356/237.3 356/237.4) and (wafer semiconductor)) and (liquid etchant)) and nebulizer	USPAT	2003/03/26 13:57
-	6	((356/316 356/36 250/288 356/237.2 356/237.3 356/237.4) and (wafer semiconductor)) and (liquid etchant)) and (peristaltic)) (((356/316 356/36 250/288 356/237.2 356/237.3 356/237.4) and (wafer semiconductor)) and (liquid etchant)) and (peristaltic))	USPAT	2003/03/26 13:57
-	27	((356/316 356/36 250/288 356/237.2 356/237.3 356/237.4) and (wafer semiconductor)) and (liquid etchant)) and (peristaltic)) (((356/316 356/36 250/288 356/237.2 356/237.3 356/237.4) and (wafer semiconductor)) and (liquid etchant)) and nebulizer)	USPAT	2003/03/26 13:57
-	27	((356/316 356/36 250/288 356/237.2 356/237.3 356/237.4) and (wafer semiconductor)) and (liquid etchant)) and (peristaltic)) (((356/316 356/36 250/288 356/237.2 356/237.3 356/237.4) and (wafer semiconductor)) and (liquid etchant)) and nebulizer))	USPAT	2003/03/26 13:57
-	5945	"peristaltic pump"	USPAT	2003/03/27 08:26
-	274	"peristaltic pump" and (wafer semiconductor)	USPAT	2003/03/27 10:56
-	1	"plasma optical emissions spectrometer"	USPAT	2003/03/27 08:41

-	88	"peristaltic pump" and (wafer semiconductor)and etch\$3	USPAT	2003/03/27 10:58
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